

Synthesis of Biaryls by Intramolecular Radical Aryl Migration from Silicon to Carbon

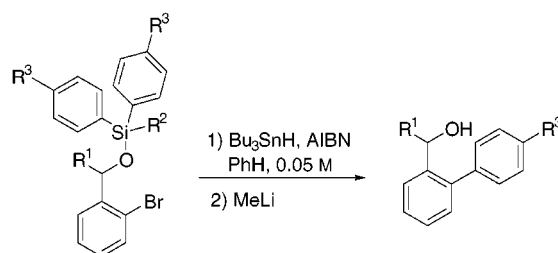
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ABSTRACT



A new method for the preparation of biaryls via intramolecular 1,5 aryl migration reaction from silicon in silyl ethers to aryl radicals is presented. Various readily available diphenylsilyl ethers can be used as substrates in this reaction. Functionalized aryl groups can also be transferred. The analogous 1,4 aryl migration reaction is less efficient.

Biaryls are an important class of compounds which occur in many natural products.¹ Moreover, biaryls have found widespread application as ligands in catalytic asymmetric synthesis.² They are also found as components in new organic materials, such as electroluminescent conjugated polymers,³ semiconductors, and liquid crystals.⁴

Most often, biaryls are prepared by transition metal-catalyzed cross-coupling reactions.⁵ Radical chemistry has also successfully been used to construct the biaryl unit. Motherwell has shown that biaryls can be prepared under mild conditions by intramolecular radical aryl migration reactions from sulfur in sulfones and sulfonamides to aryl radicals.⁶ Similar transformations where aryl migration occurs

from oxygen in phenyl ethers to aryl radicals have been disclosed.⁷ Amides⁸ as well as diazenes⁹ have been used as linkers in aryl migration reactions. In these systems, the aryl moiety is transferred from nitrogen to aryl radicals. Biaryls have also been prepared via intramolecular aryl migration from carbon to aryl radicals.¹⁰

Recently, we presented the phenyl migration reaction from silicon to secondary C-centered radicals as a new method for the stereoselective C(sp²)-C(sp³) bond formation (Scheme 1).¹¹ In this Letter we disclose our first results on the application of this method for the preparation of biaryls.¹²

As in our previous studies, we decided to use the silyl

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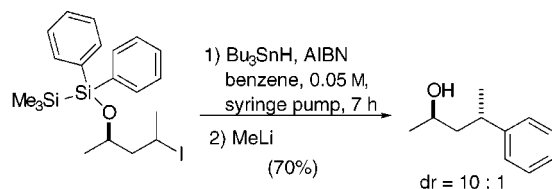
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Scheme 1. Stereoselective Radical Phenyl Migration from Silicon to Carbon



ether functionality to link the attacking aryl radical with the migrating aryl group. Silicon tethers have often been used to transform an *intermolecular* reaction to an *intramolecular* process, a concept often called the Stork¹³ temporary silicon connection.¹⁴ However, in the aryl migration reactions from Si to aryl radicals discussed herein, the tether is cleaved during the reaction as will be discussed in the mechanistic section of the paper. Differently substituted diphenylsilyl ethers **1–7** were readily prepared from the corresponding chlorosilanes and benzyl alcohols using standard conditions.^{15–17} Phenyl migrations were performed by slow addition (syringe pump, 7 h) of Bu₃SnH and AIBN to a solution of the silyl ether in benzene (0.05 M). After complete addition, stirring was continued for 30 min and the reaction mixture was then allowed to cool to room temperature. Desilylation using methyllithium¹⁸ afforded after chromatography (SiO₂) the desired biphenyl derivatives **8** or **9** in moderate to good yields (Scheme 2, Table 1) along

Table 1. Optimization of the Phenyl Migration from Silicon to Aryl Radicals by Varying the Silyl Ether

entry	silyl ether	8 (%)	10 (%)
1	1	55	28
2	2	52	39
3	3		84
4	4	56	
5	5	52	
6	6	71	

with silylated benzyl alcohol **10** (for **1–3**). The side product **10** derives from intramolecular homolytic substitution at

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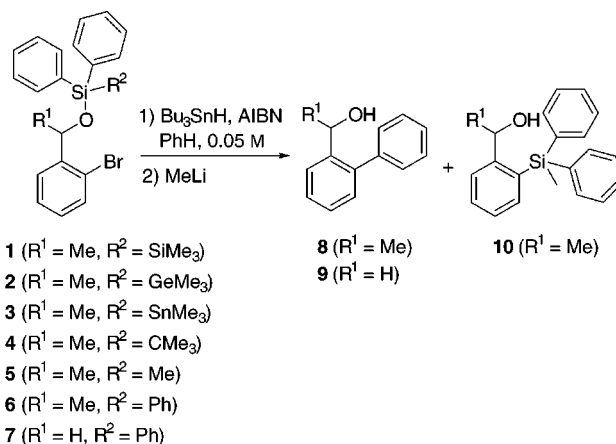
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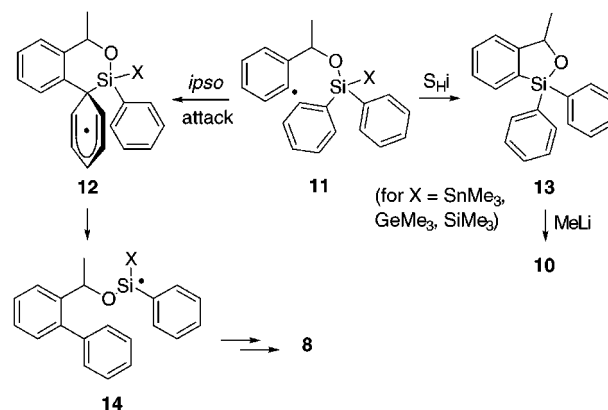
(15) **1** from ClSiPh₂SiMe₃¹⁶ and 1-(2-bromophenyl)ethanol (NEt₃, DMAP, THF, 92%); **2** in analogy from ClSiPh₂GeMe₃¹⁷ (71%); **3** in analogy from ClSiPh₂SnMe₃¹⁶ (60%); **4** in analogy from ClSiPh₂-*t*-Bu (74%); **5** in analogy from ClSiPh₂Me (84%); **6** from ClSiPh₃ and imidazole in DMF (37%); **8** from benzyl alcohol and ClSiPh₃ in pyridine/toluene (1:1, 64%).

Scheme 2. Radical Phenyl Migration from Silicon to Aryl Radicals



silicon (S_{Hi})^{17,19} and subsequent ring opening of the intermediate cyclic silyl ether with MeLi (see Scheme 3).

Scheme 3. Mechanism



As expected from our previous studies on the S_{Hi} reaction at silicon,^{17,19} no biphenyl **8** was formed in the reaction of stannylated silyl ether **3** and the S_{Hi}-derived alcohol **10** was isolated in 84% yield (Table 1, entry 3). Phenyl migration to the aryl radical generated from **3** is too slow to compete with the S_{Hi} reaction. For germlylated or silylated silyl ethers, the S_{Hi} reaction with primary alkyl radicals is about 100–1000 times slower than the corresponding reaction with stannylated silyl ethers.¹⁷ Similar kinetics may also be expected for the S_{Hi} reaction at silicon with aryl radicals;

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thus, the $S_{\text{H}}\text{I}$ reaction should be suppressed for silylated as well as for germylated silyl ethers, and the desired phenyl migration should be the major reaction pathway. Indeed, the phenyl migration product **8** is the main product in the reaction of **1** (55%) and the $S_{\text{H}}\text{I}$ -derived alcohol **10** was isolated in only 28% yield (entry 1). Similar results were obtained for the germylated silyl ether **2**, where biphenyl **8** was isolated in 52% yield along with 39% of the side product **10** (entry 2).

To completely suppress the $S_{\text{H}}\text{I}$ reaction, the heavier group 14 substituent (R^2 in Scheme 2) was replaced by an alkyl or a phenyl group. For all these diphenylsilyl ethers (**4**–**6**), phenyl migration worked well, and biphenyl **8** was isolated in good yields (52–71%, entries 4–6). An additional advantage of **4**–**6** over their silylated or germylated congeners besides suppression of the undesired $S_{\text{H}}\text{I}$ reaction is the fact that they are derived from commercially available chlorosilanes. To illustrate that issue, we prepared biphenyl **9** from commercially available 2-bromobenzyl alcohol and triphenylchlorosilane in two steps via silylation (pyridine/toluene, \rightarrow **7**, 64%, unoptimized) and subsequent phenyl transfer reaction (52%). As a side product, benzyl alcohol, derived from direct reduction of the initially formed aryl radical (dehalogenation) and subsequent removal of the triphenylsilyl group, was formed in 17%.

For the phenyl migration, we suggest the following mechanism (Scheme 3). Depending on the substituent X, aryl radical **11** either undergoes $S_{\text{H}}\text{I}$ reaction at silicon to form cyclic silyl ether **13** or it reacts with one of the two phenyl groups to form radical **12**, which then rearomatizes to form silyl radical **14**. Radical **14** can either abstract a halogen atom from the starting bromide²⁰ or it can react with benzene in a homolytic aromatic substitution.²¹ Desilylation (MeLi) then affords biphenyl **8**. In the other reaction pathway, ring opening of **13** with MeLi eventually leads to alcohol **10**.

We also tried to run the phenyl migration reaction using catalytic amounts of tin hydride. Reaction of **6** with 18% Bu_3SnH and 4% AIBN under otherwise identical conditions (benzene, 0.05 M, syringe pump, 7 h) afforded after desilylation alcohol **8** in only 21% along with 72% of 1-(2-bromophenyl)ethanol derived from unreacted starting material. Thus, halogen abstraction of silyl radical **14** does not seem to be the major reaction pathway.

We next tested whether it is possible to transfer functionalized aryl groups from silicon to aryl radicals. To this end, silyl ethers **15**–**19** were prepared from the corresponding chlorosilanes.²²

For the *p*-fluoro derivative **15**, the aryl migration product **20** was formed in 49% (Table 2, entry 1). Reaction with thienyl derivative **16** afforded an inseparable product mixture. Compound **21** could not be clearly identified (entry 2). With *tert*-butylated silyl ethers **17** and **18**, the results obtained were

Table 2. 1,5-Migration of Functionalized Aryl Groups

entry	bromide	R	aryl	yield (%)
1	15	SiMe_2Ph		49 (20) ^a
2	16	SiMe_2Ph		– ^b
3	17	<i>t</i> -Bu		35 (20)
4	18	<i>t</i> -Bu		– ^c
5	19	Me		77 (22)

^a The corresponding $S_{\text{H}}\text{I}$ product was formed as a side product. ^b Various inseparable products were formed. ^c Various inseparable products were formed. In addition, 46% of **18** were recovered.

similar to those for the corresponding disilyl ethers **15** and **16** (entries 3 and 4). The best result was obtained for the transfer of the *p*-methoxyphenyl group (\rightarrow **22** (77%), entry 5).

We then studied the 1,5 phenyl migration to vinyl radicals. The aryl migration reactions were conducted under the above-mentioned conditions. Unfortunately, neither for **23** nor for **24** (Figure 1) did phenyl migration occur. To our

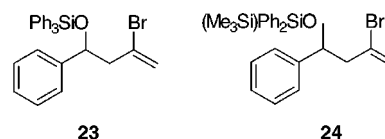


Figure 1.

surprise, no reduction product (dehalogenation) was formed in the reaction of **23** and the starting bromide was recovered. For **24** only 28% of the dehalogenation product was observed along with unreacted bromide as determined by ^1H NMR spectroscopy. We also tried to reduce bromide **24** under radical dehalogenation conditions (addition of tin hydride in one portion at higher concentration). However, even under these conditions only 45–50% of the dehalogenation product was formed (^1H NMR) and no phenyl migration was observed.

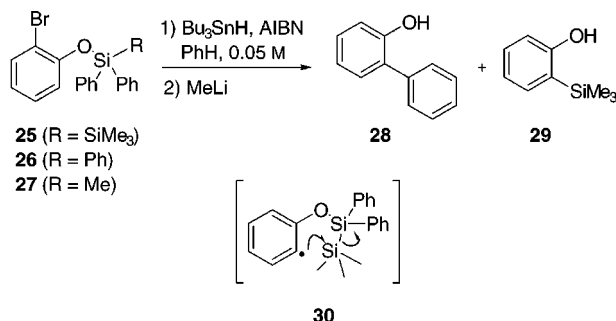
Finally, we investigated the 1,4 phenyl migration from silicon to aryl radicals. Silyl ethers **25**–**27** were prepared from *o*-bromophenol using $\text{ClSiPh}_2\text{SiMe}_3$ ¹⁶ or ClSiPh_2Me and NEt_3/DMAP in THF (for **25**, **27**) or ClSiPh_3 and $\text{NEt}_3/$

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Scheme 4. 1,4 Phenyl Migration from Silicon to Aryl Radicals



DMAP in CH₂Cl₂ (**26**) (Scheme 4). The aryl migrations were performed under our standard aryl transfer conditions. Interestingly, transformation of **25** afforded silylated phenol **29** as the major product in 50% yield along with the desired biphenyl derivative **28** (38%). Phenol **29** is formed via initial S_Hi reaction at silicon (see **30**). This is the first time in our studies on the homolytic substitution at silicon^{17,19} that a trimethylsilyl group migration was observed. Obviously, the transition state of the 4-*exo* attack at the silicon next to the oxygen atom is too strained and 5-*endo* attack at the silicon atom on the periphery occurs in addition to *ipso* attack (minor pathway). Trimethylsilyl group migrations to heteroatom-centered radicals are well-known;²³ however, similar migrations to C-centered radicals have not been observed so far.²⁴ Interestingly, no products derived from *ortho* attack at the phenyl group were observed.⁶

To suppress the S_Hi reaction, the trimethylsilyl group in **25** was replaced by a phenyl group (**26**). However, neither phenyl migration nor dehalogenation was observed in the reaction of **26**. After desilylation, *o*-bromophenol was

recovered in 71% yield. It turned out that even upon adding Bu₃SnH in one portion to the bromide, no reaction occurred. Since silyl ether **26** was carefully purified by chromatography followed by recrystallization, we do not believe that phenol impurities are the reason for the failure of the radical reaction. Neither with tris(trimethylsilyl)silane²⁵ nor with tin chloride in *t*-BuOH in the presence of cyanoborohydride²⁶ was any reaction observed. Even SmI₂ in THF (HMPA) did not lead to any aryl migration. It seems that the triphenylsilyl group completely blocks the bromide. We also obtained an X-ray structure of **26**. Surprisingly, in the solid state the bromide is not protected by the silyl group and reaction with tin radicals seems to be feasible. Also for **27** bearing the smaller methyl substituent, no radical reaction was observed. Although the X-ray structure of **26** did not offer the final answer, we believe that in solution the bulky silyl group protects the bromide toward any attack.

In conclusion, we present a new method for the preparation of biaryls by intramolecular aryl migration from silicon to aryl radicals. The starting materials are readily prepared from commercially available silicon protecting groups and experiments are very easy to conduct.

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Supporting Information Available: Full experimental details, spectroscopic and analytical data for all new compounds, and X-ray structural data for **26** (CCDC-141621). This material is available free of charge via the Internet at <http://pubs.acs.org>.

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